

(Use several sheets if necessary)

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		Nuyken, O. et al., "Laser ablation of arylazo-containing polymers", POLYMER NEWS (1999), 24(8), 257-266
		Nuyken, O. et al., "Synthesis of Polysulfides Containing the Triazeno Group and Their Application as Photoresists in Excimer Laser Polymer Ablation", CHEMISTRY OF MATERIALS (1997), 9(2), 485-494
		Wei, J. et al., "Novel Laser Ablation Resists for Excimer Laser Ablation Lithography. Influence of Photochemical Properties on Ablation", JOURNAL OF PHYSICAL CHEMISTRY B (2001), 105(6), 1267-1275

DATE CONSIDERED

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